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·	Application No.	Applicant(s)	
Notice of Allowability	10/809,650	COTE ET AL.	
Notice of Anomapinty	Examiner	Art Unit	
	Geraldine V Letscher	1752	
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIG of the Office or upon petition by the applicant. See 37 CFR 1.313	OR REMAINS) CLOSED in to other appropriate commur GHTS. This application is su	his application. If not included	roe TIUC
1. This communication is responsive to papers filed September	er 2, 2004.		
2. The allowed claim(s) is/are 19-34.		•	
3. \boxtimes The drawings filed on <u>26 March 2004</u> are accepted by the E	xaminer.		
 4. ☐ Acknowledgment is made of a claim for foreign priority und a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 		(f).	
		KI.	
 2. ☐ Certified copies of the priority documents have been received in Application No 3. ☐ Copies of the certified copies of the priority documents have been received in this national stage application from the 			
International Bureau (PCT Rule 17.2(a)).	uments have been received i	ii this national stage application	from the
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONME THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO 450) which	ENT of this application. ted Note the attached EXAM	INER'S AMENDMENT OF NOTICE	
INFORMAL PATENT APPLICATION (PTO-152) which gives		eclaration is deficient.	
6. CORRECTED DRAWINGS (as "replacement sheets") must			
(a) ☐ including changes required by the Notice of Draftsperso1) ☐ hereto or 2) ☐ to Paper No./Mail Date	n's Patent Drawing Review (PTO-948) attached	
(b) including changes required by the attached Examiner's	Amondmont / Comment :-	H- Off C	
Paper No./Mail Date	Amendment / Comment or in	the Office action of	
Identifying indicia such as the application number (see 37 CFR 1.8 each sheet. Replacement sheet(s) should be labeled as such in the	4(c)) should be written on the calculation and the calculations are seen according to 37 CFR	drawings in the front (not the back	() of
7. DEPOSIT OF and/or INFORMATION about the deposi attached Examiner's comment regarding REQUIREMENT FOR	t of BIOLOGICAL MATER	IAI must be submitted. Note t	the
•			
Attachment(s)			
1. Notice of References Cited (PTO-892)		mal Patent Application (PTO-152	2)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Sum	mary (PTO-413), il Date	
3. Information Disclosure Statements (PTO-1449 or PTO/SB/08) Paper No./Mail Date <u>5-27-04</u>	7. Examiner's Am	nendment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's Sta	tement of Reasons for Allowanc	е
of Biological Material	9. 🗌 Other		
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•		Ynder for.	
U.S. Patent and Trademark Office		/ / /	

GERALDINE LETSCHER
PRIMARY EXAMINER
GROUP 1100

Part of Paper No./Mail Date 1

Application/Control Number: 10/809,650

Art Unit: 1752

Election/Restrictions

1. Responsive to the election requirement of August 18, 2004, applicants have canceled claims 1-18. Claims 19-34 are pending in this application.

Allowable Subject Matter

2. The following is an examiner's statement of reasons for allowance:

The claimed integrated circuit produced from a photolithographic mask of a target pattern in a layer of material of the integrated circuit of the instant claims 19-26 is distinguished from the prior art in that the layer of material of the integrated circuit comprises a plurality of features defined by a plurality of shifter shapes of the photolithographic mask whereby at least part of space is left between adjacent shifter shapes to admit a cut. The claimed method of manufacturing an integrated circuit of the instant claims 27-34 is distinguished from the prior art in that radiation-sensitive material is exposed to a target pattern defined by utilizing a plurality of shifter shapes of the photolithographic mask whereby at least part of space is left between adjacent shifter shapes to admit a cut.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

3. Claims 19-34 are allowed.

Art Unit: 1752

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Geraldine V Letscher whose telephone number is (571) 272-1334. The examiner can normally be reached 7:30am to 4:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Cynthia Kelly can be reached on (571) 272-1526. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

GERALDINE LETSCHER PRIMARY EXAMINER GROUP 1100

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